



Welcome to KLA's

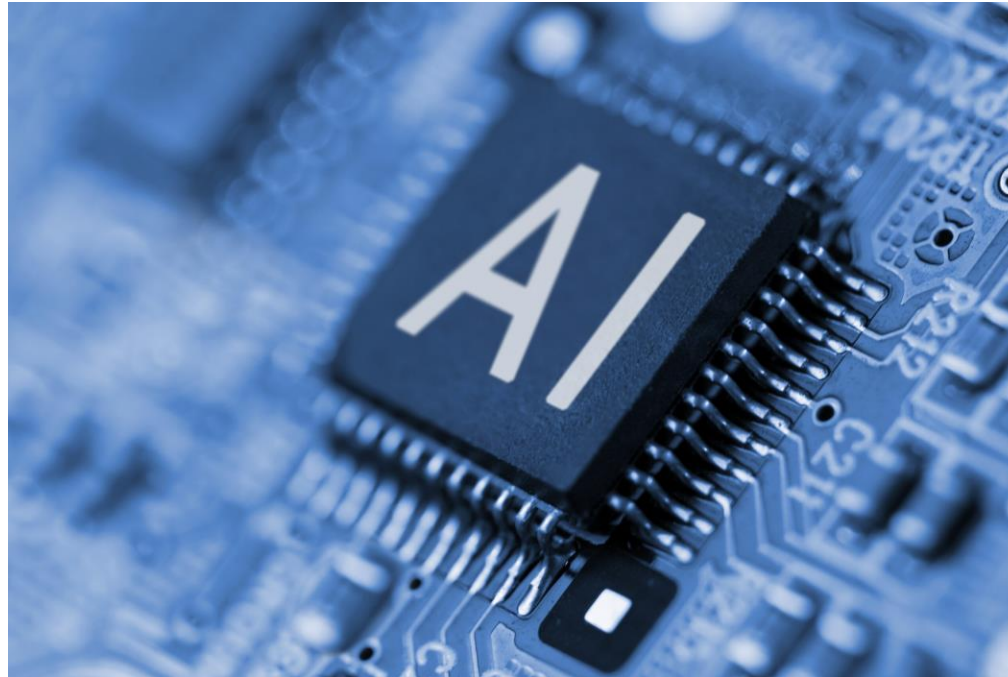
Software Engineering Workshop

Jan 12, 2024

Agenda for the day

8:15am	Problem statement description
8:45am	Students download input dataset & problem description
9:00am	Q&A Students start investigating & solving the problem
9:30am onwards	Mentor assigned to you will check-in and connect
	Mentors will check-in with you hourly and guide
1:00pm	Lunch
5:00pm	Final cut off to submit results and final mentor check-ins
6:15pm	Results announcement

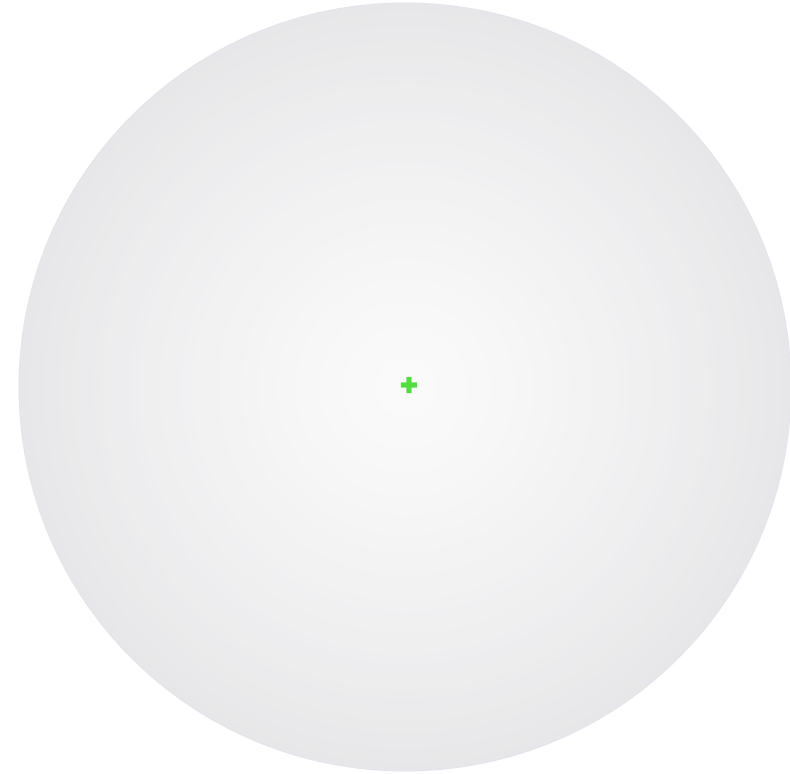
Silicon Chip



Wafer manufacturing process

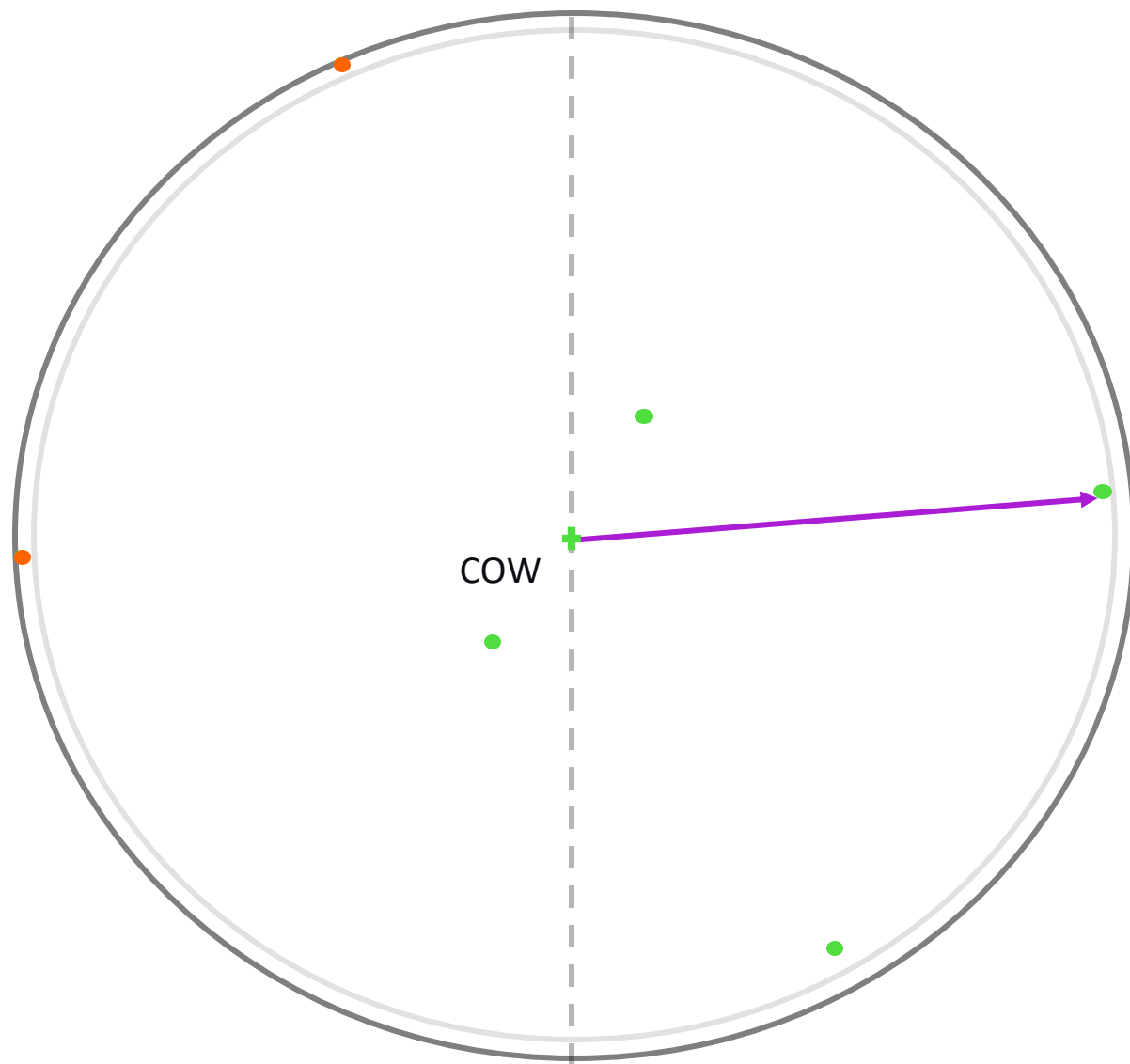








Silicon Ingot



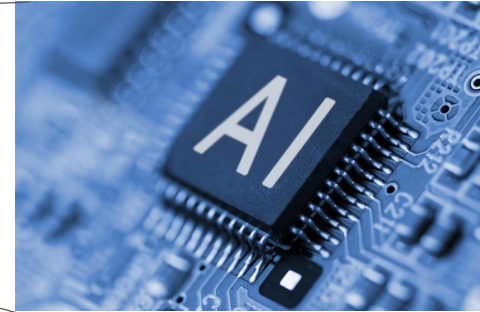
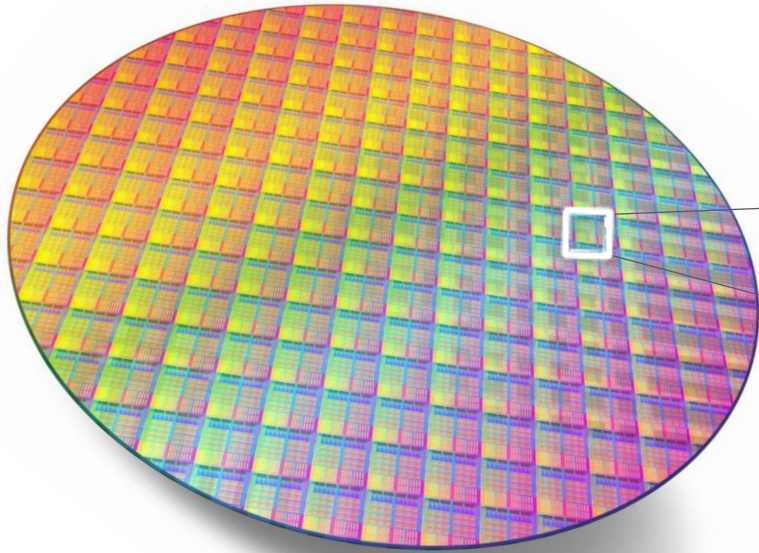
Bare wafer

Bare wafer



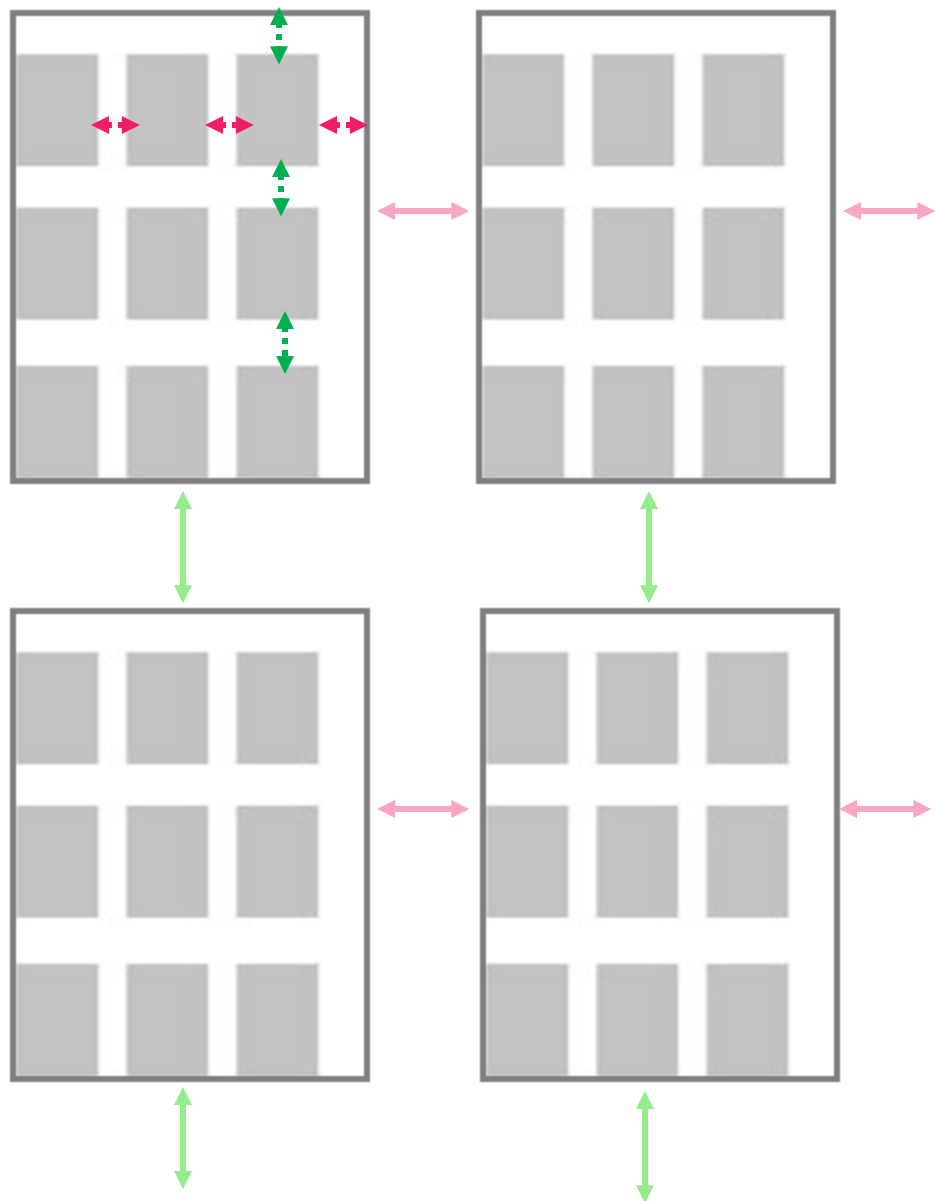
-  Center of wafer
-  Wafer Size (mm)
-  Measurement Location in wafer coordinate
-  Distance from COW -> Measurement location
-  Edge exclusion boundary
-  Excluded Measurement locations





Patterned wafer

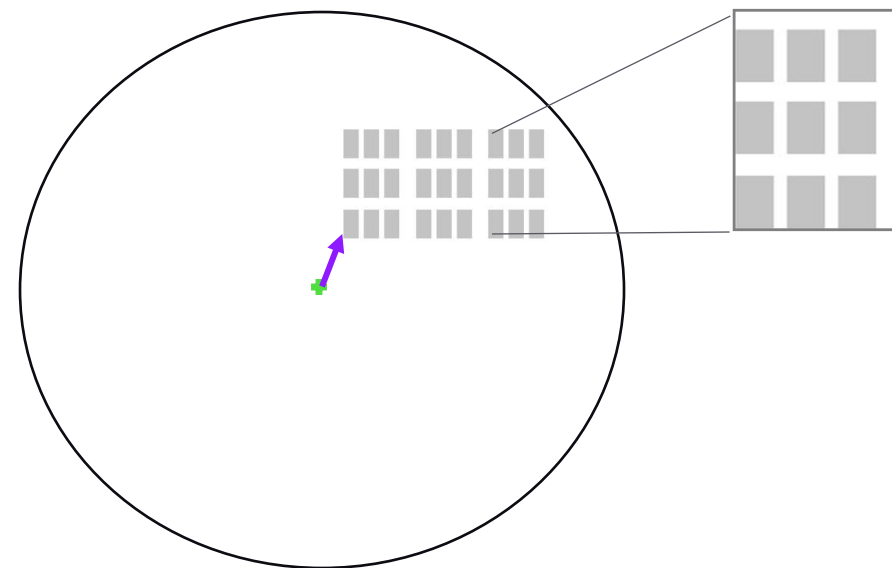


Patterned wafer

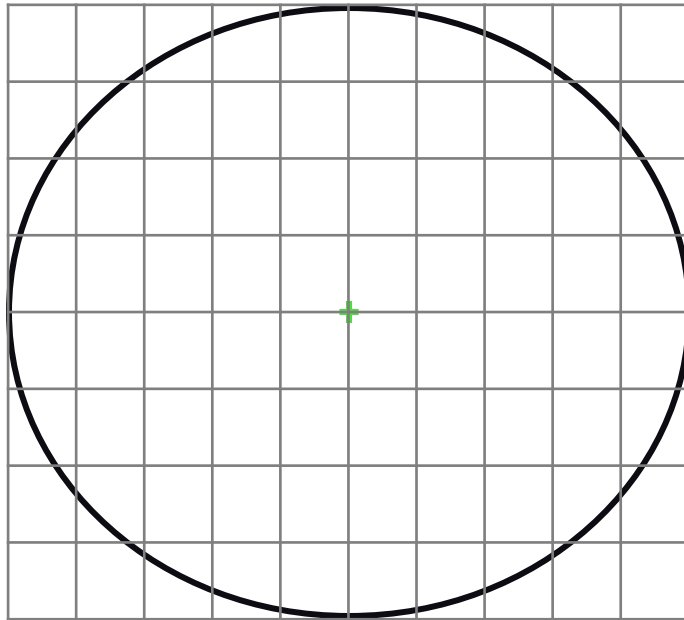
Reticle, Die & street



-  Die street width
-  Die street height
-  Reticle street width
-  Reticle street height

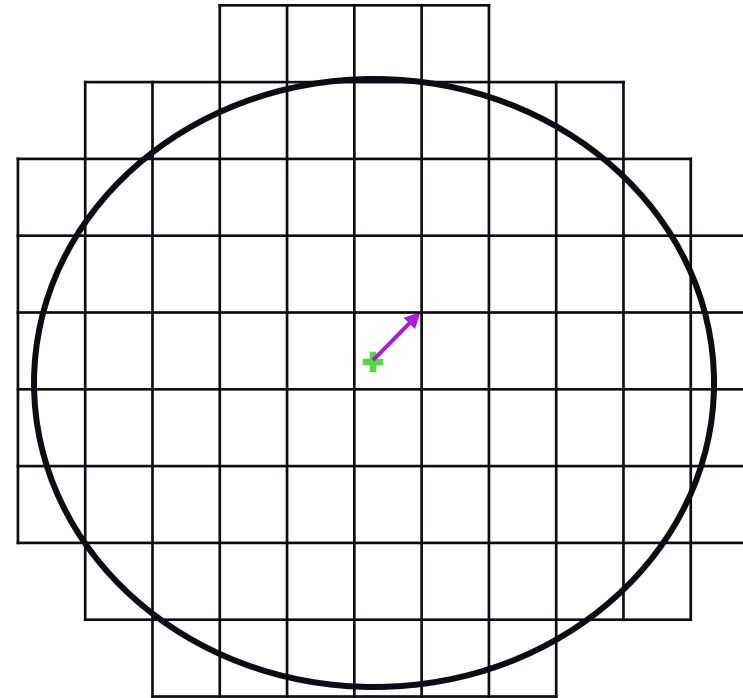


Die shift (Reticle with 1x1 die)



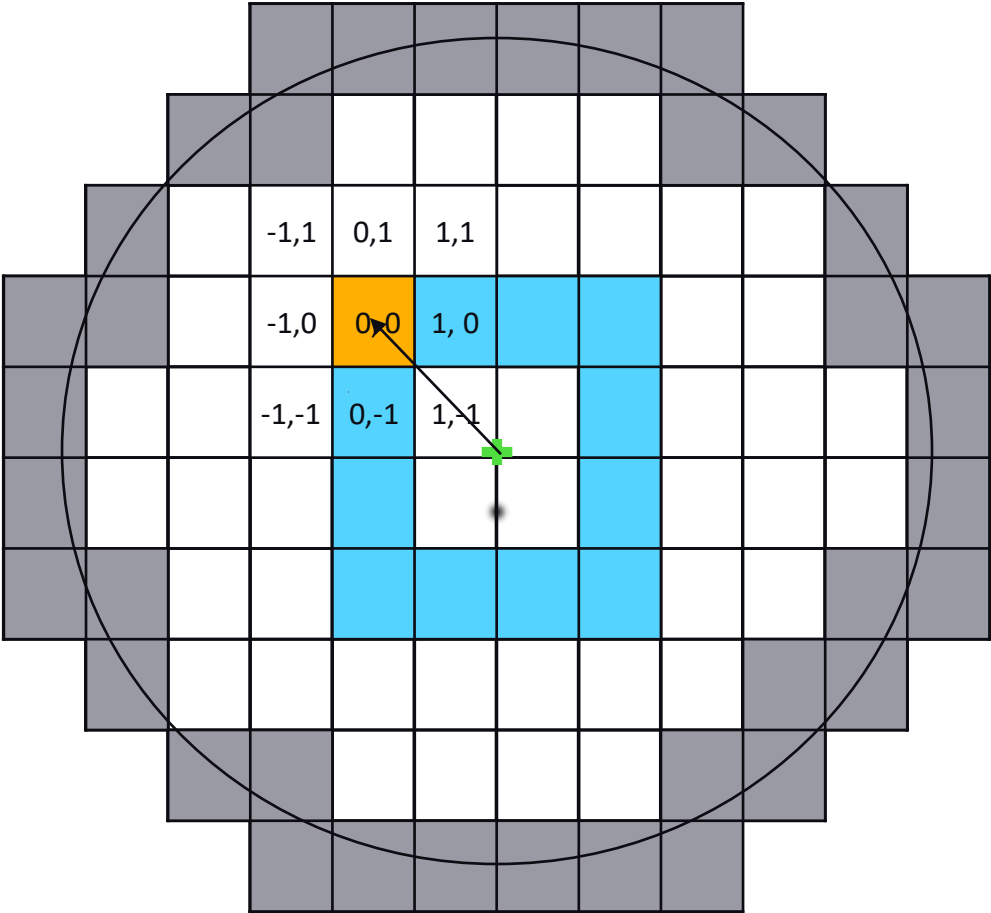
Die Shift vector from COW = 0






- + COW
- Die Shift vector (COW to Lower left die in Reticle)



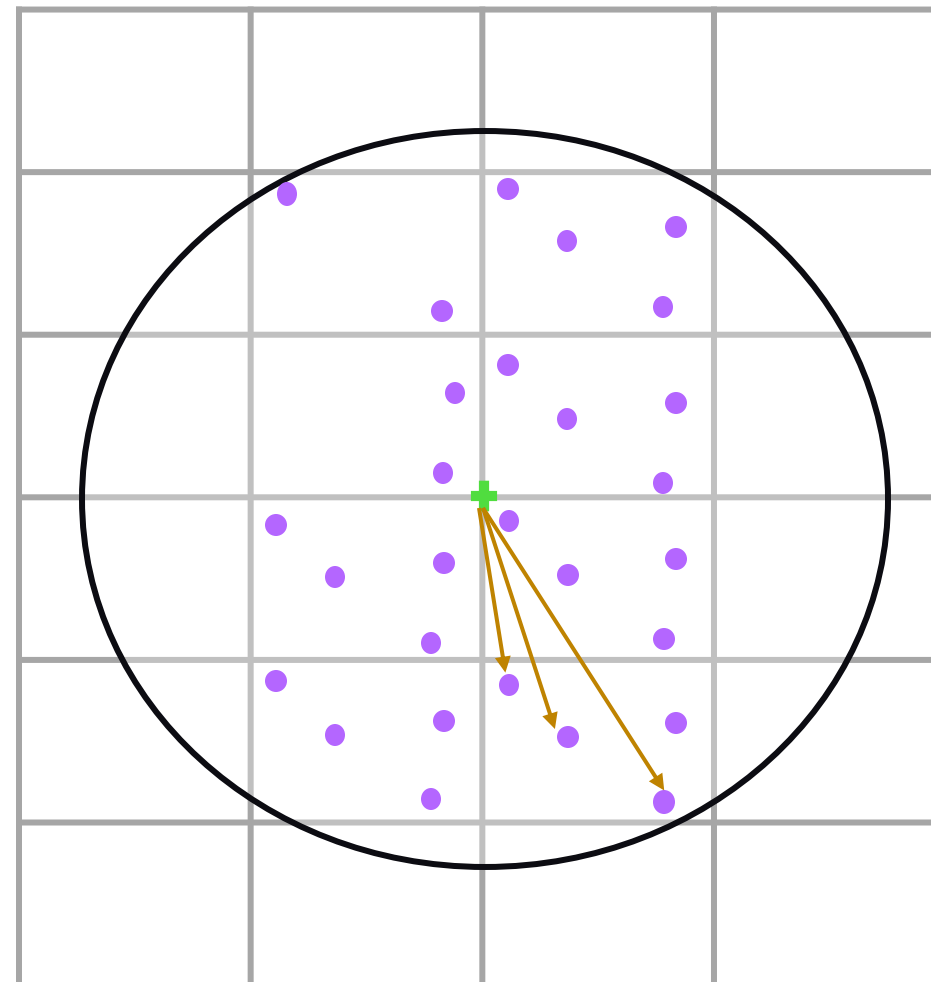
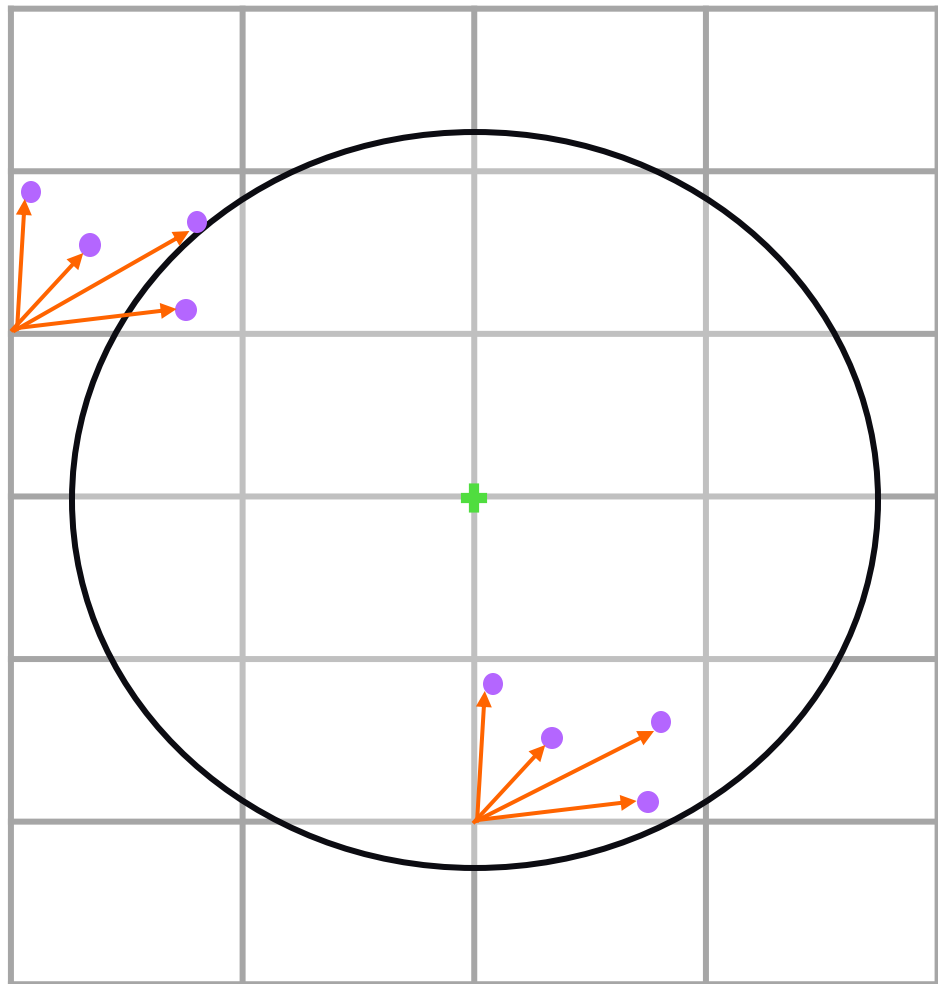
Die Shift vector from COW = (+,+)

Die Index, Reference die, Partial and Measurement die

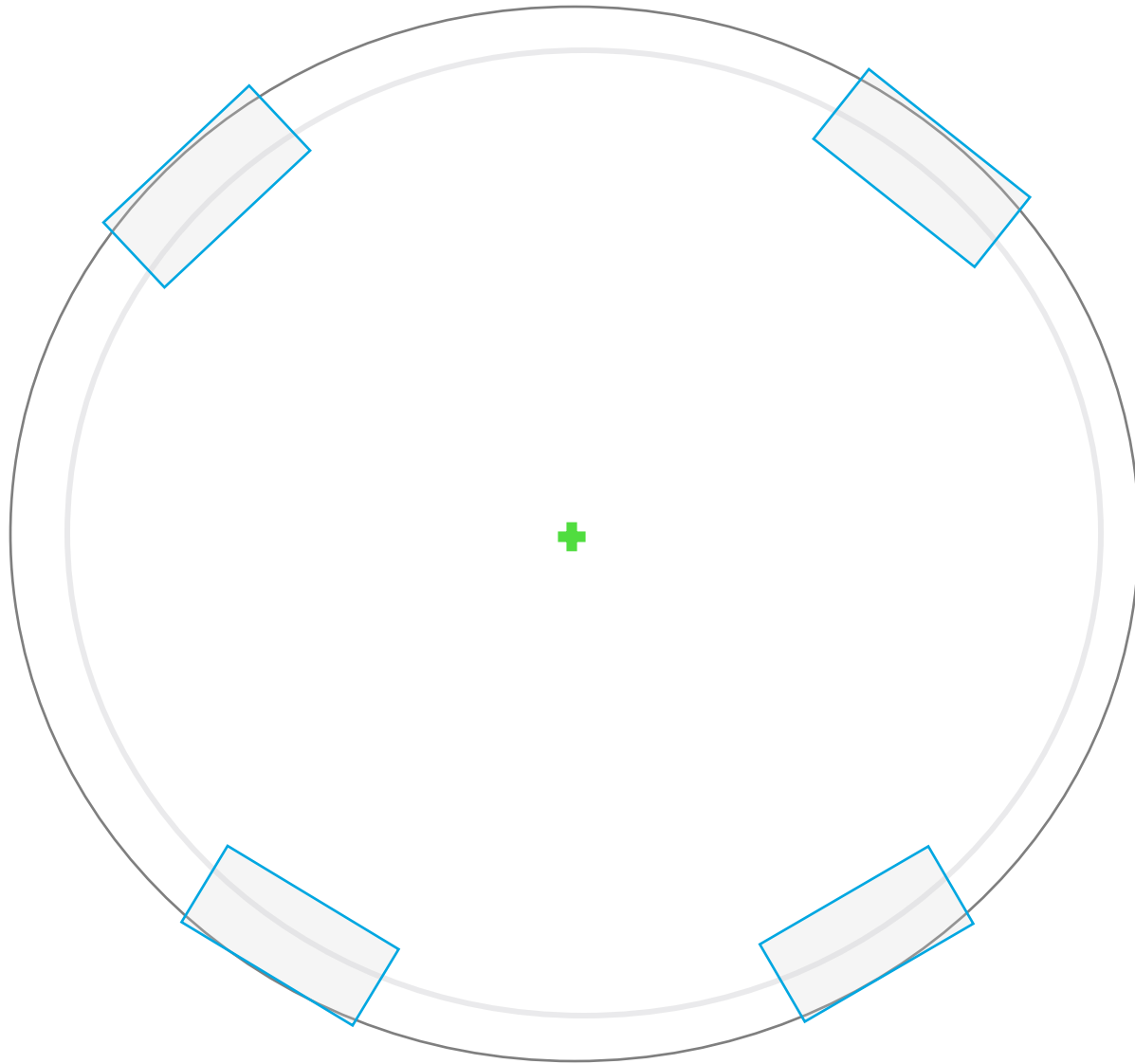


-  COW
-  User's reference die
-  COW to Center of Reference die
-  Partial die
-  Measurement die

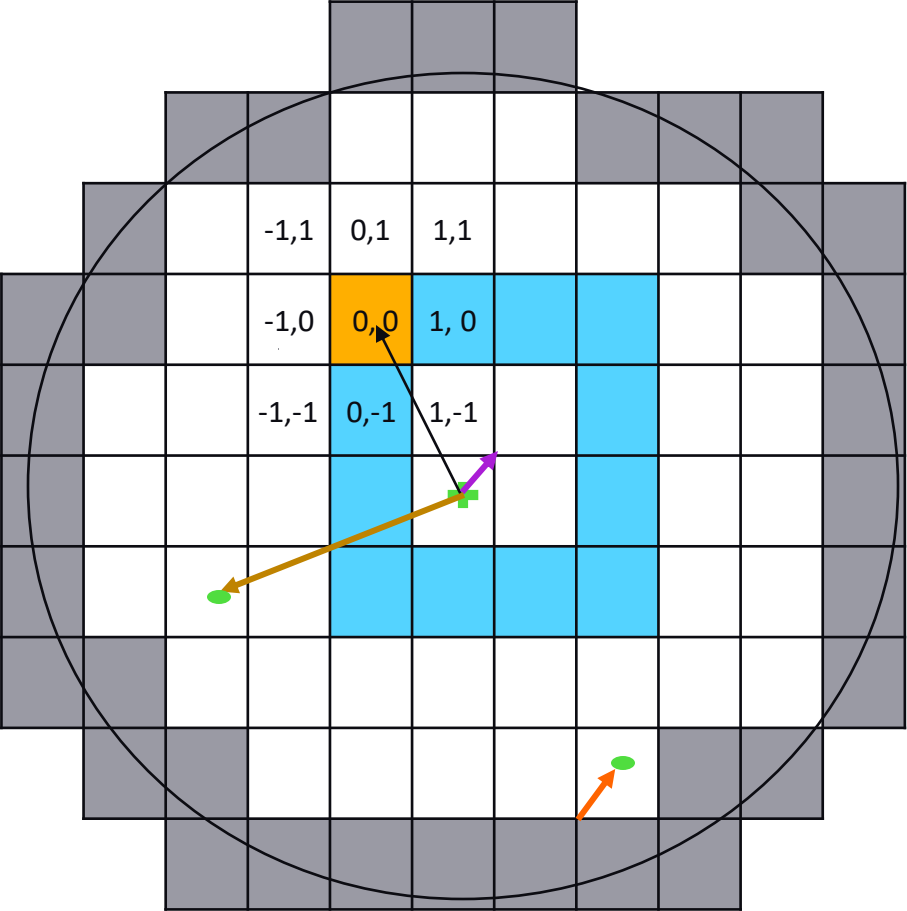
Die coordinate vs Wafer coordinate



Wafer Gripper

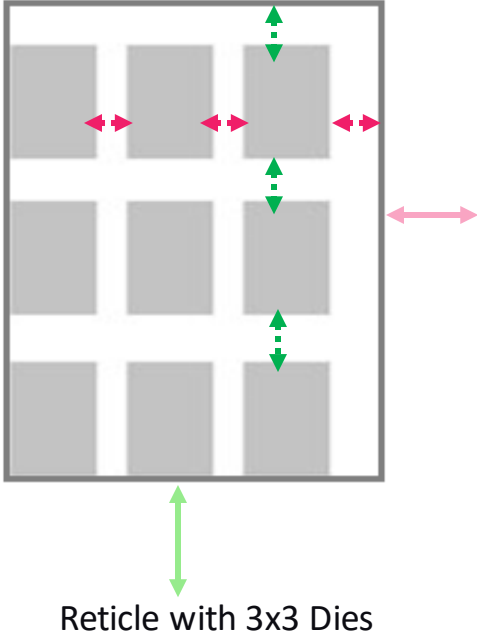


Summary



Wafer map with Reticle of 1 x 1 Dies

- Cow
- User's reference die
- Cow to Center of Reference die
- Partial die
- Measurement die
- Die Shift vector
- Measurement Location
- Distance from COW to measurement location
- Distance from Die LLC



Milestone 1 – Bare wafer map

Input

- Wafer Diameter (mm)
- N - number of equally spaced points to be generated
- Angle in (deg)

Output

- Generate N points that are equally spaced at a given angle.

Output Format (in mm)

(-120.0000, 0.0000)

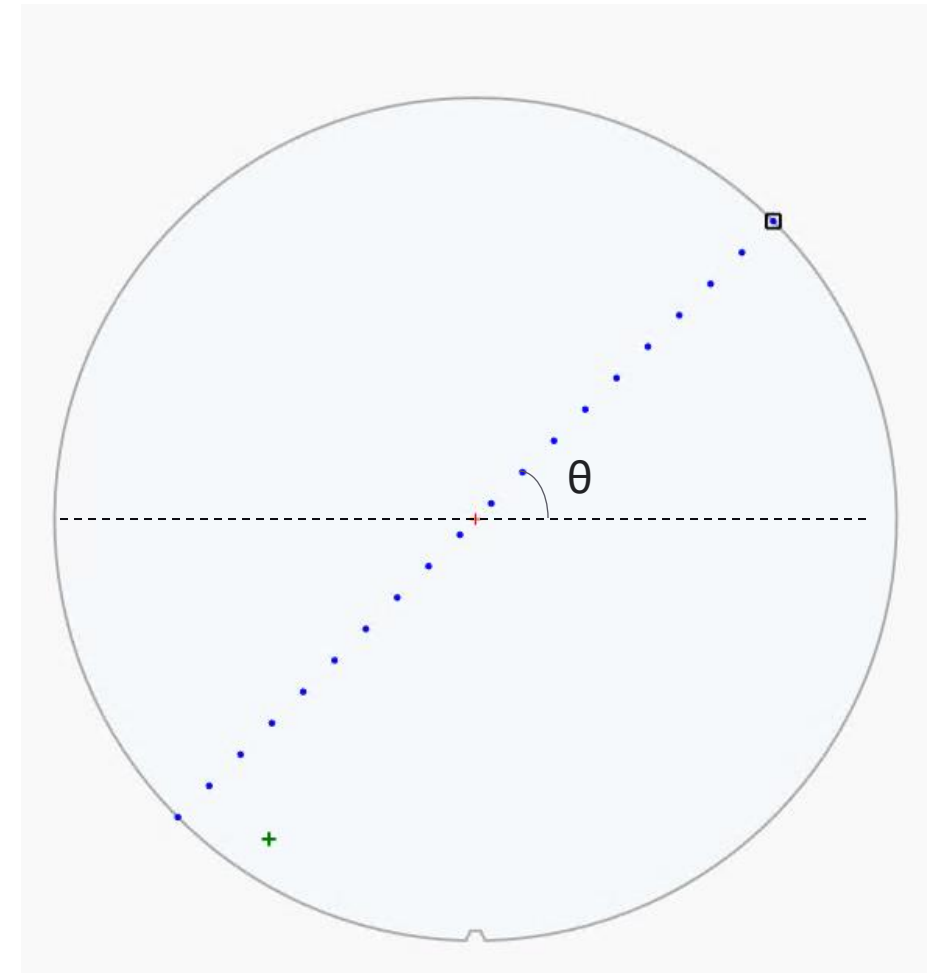
(-119.6552, 4.5000)

(-149.3103, 2.0000)

(-181.9655, 0.0000)

(-124.6207, 0.0000)

(- 98.2759, 0.0000)



Milestone 2 – Simple Pattern wafer map

Input

- Wafer Diameter (mm)
- Die size x, y (mm),
- Die shift vector x, y (mm)
- Distance from COW to Center of Reference Die x, y (mm)

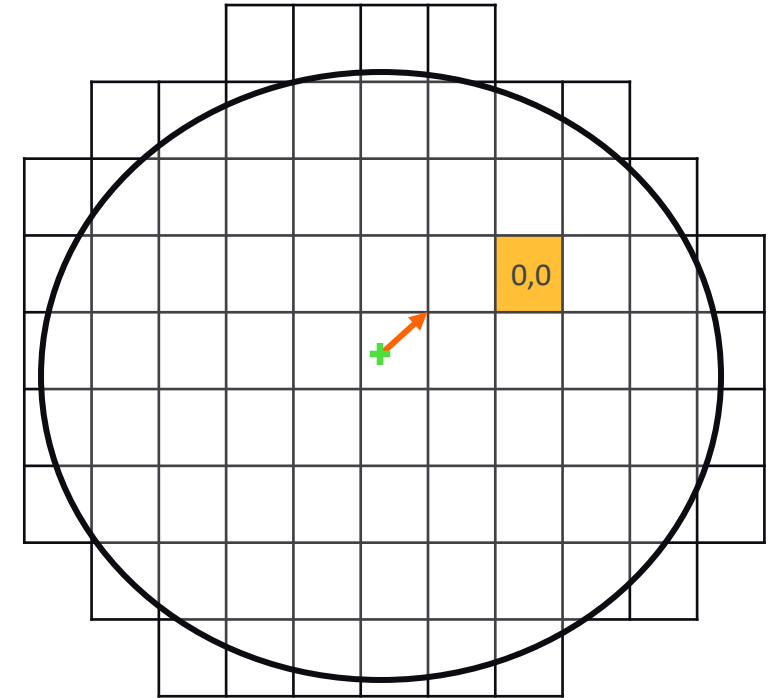
Output

- Die Index of all dies including partial dies from reference die
- LLC of all valid dies (including partial dies) in wafer coordinate

Output Format (in mm)

(0, 0) : (15.1231, 20.3200)

(2, 3) : (30.4534, 40.1223)



Die Shift vector from COW = (+,+)

Milestone 3 – Asymmetric wafer map

Input

- Wafer Diameter (mm)
- Die size x, y (mm)
- Die shift vector x, y (mm)
- Distance from COW to Center of Reference Die x, y (mm)
- **Number of dies per reticle (rows x columns)**
- **Reticle Street Width & Height (mm)**
- **Die Street Width & Height (mm)**

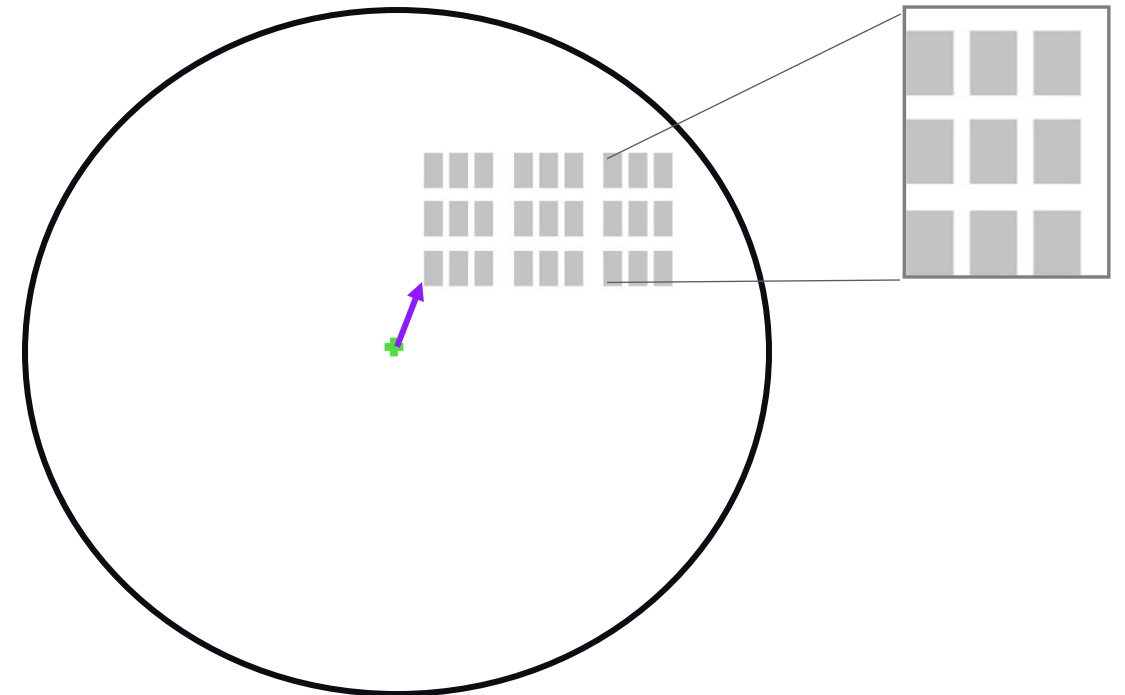
Output

- Die Index of all dies including partial dies from reference die
- LLC of all dies including partial dies in wafer coordinate

Output Format (in mm)

(0, 0) : (15.1232, 20.3212)

(2, 3) : (30.4512, 40.1232)



Milestone 4 – find measurement locations in dies on a given radius

Input

- Wafer Diameter (mm)
- Die size x, y (mm),
- Die shift vector x, y (mm)
- Distance from COW to center of Reference Die x, y (mm)
- Number of dies per reticle (rows x columns),
- Reticle Street Width & Height (mm)
- Die Street Width & Height (mm)
- **Radius (mm)**
- **Die coordinates (mm) of Locations to be measured**

Output

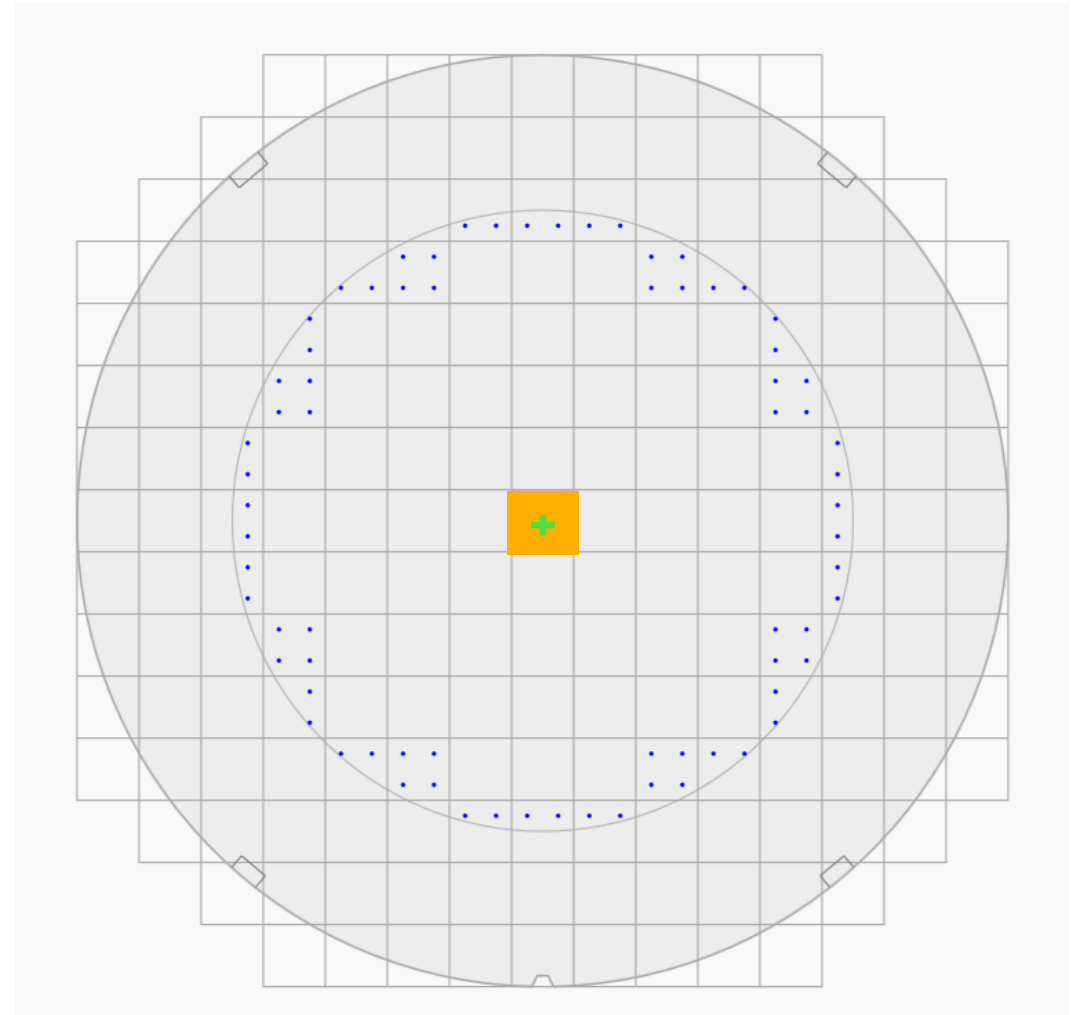
- Die Index of dies that intersect on a given radius .
- Wafer Coordinates of the measurement locations in the intersecting dies that fall inside the given radius.

Output Format (in mm)

(5,0) : (45.1232, 2.3243)

(5,0) : (47.1232, -2.3243)

(5,-1) : (47.4512, -7.1234)



Milestone 5 – find valid die coordinates of Meas. Locs & die index

Input

- Wafer Diameter (mm)
- Die size x, y (mm),
- Die shift vector x, y (mm)
- Distance from COW to Center of Reference Die x, y (mm)
- Number of dies per reticle (rows x columns)
- Reticle Street Width & Height (mm)
- Die Street Width & Height (mm)
- **4 Gripper angles (deg)**
- **Gripper width and height (mm)**
- **Circular Edge exclusion (mm)**
- **List of wafer coordinates to measure (mm)**

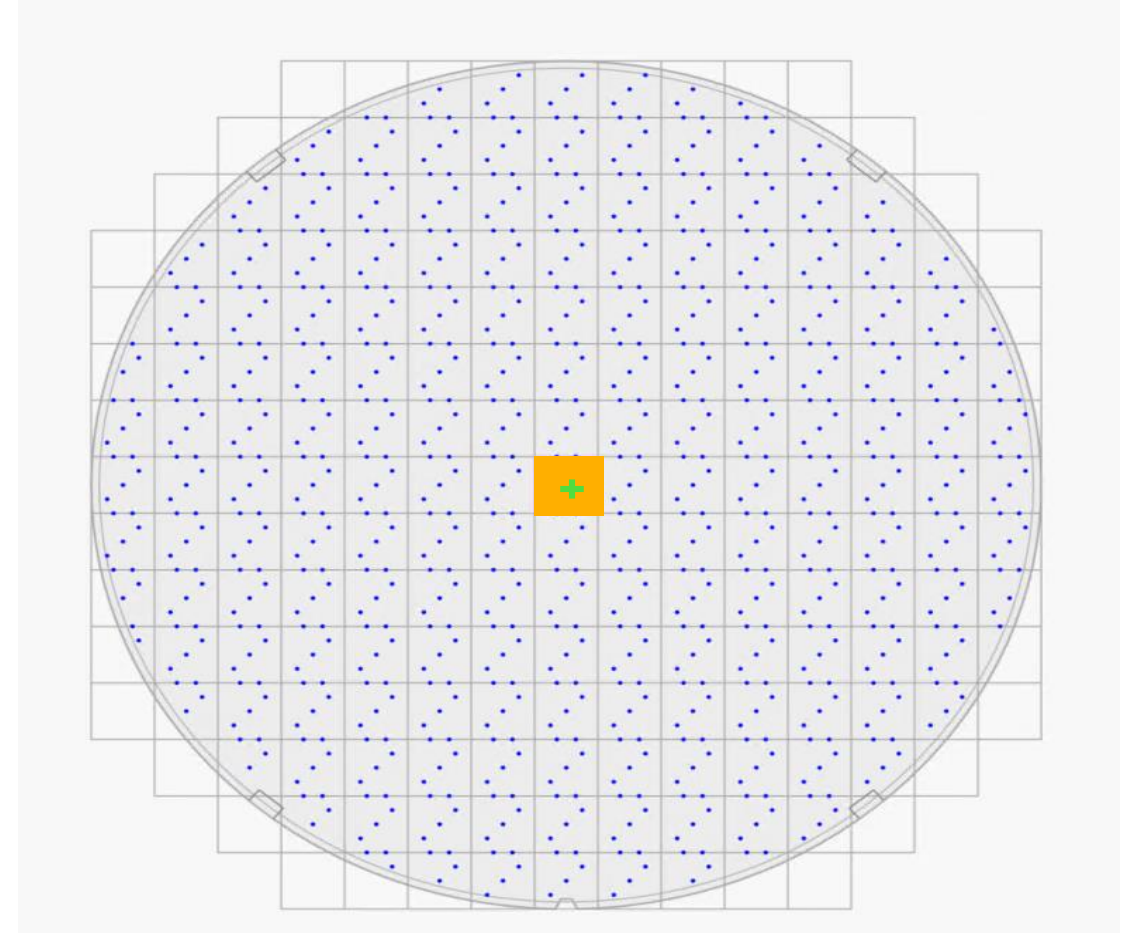
Output

- Die Index & die Coordinates of meas. locations available in valid regions.

Output Format (in mm)

(0,0) : (15.1243, 20.3222)

(2,3) : (30.4512, 40.1243)



Student guideline

- Student Input Location (Input files, Validation utility, Problem statement pdf, dependent files)
 - FTP link <https://fft.kla-tencor.com/login?local=true>
 - Username: KLAUniversityWorkshop2024
 - Pwd: KLAUniversityWorkshop-2024

Install the Aspera plugin extension if required.

- Make a source code check in to git hub every hour / after every milestone.
- Share the Github public repo access to klauniversityworkshophiring@gmail.com
- Use appropriate data structure, class objects & efficient algorithms. Mentors will review the various solution approaches & code quality.

Solution validator

<https://klasolutionvalidator2024.azurewebsites.net/>

KLA Workshop - Solution Validator

Student Roll Number

Full Name

College Name

Milestone

Testcase

Upload your Solution: No file chosen

End